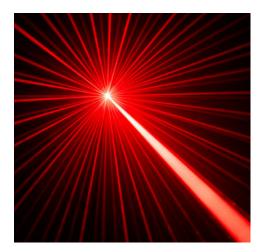
Develop on Press Thermal Negative Offset Plate



NO CHEMISTRY - NO PROCESSOR

4 EASY STEPS TO PRODUCTION

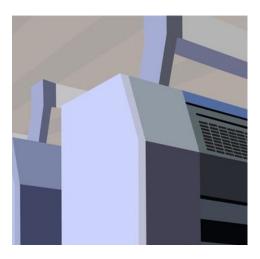


EXPOSE

Fast 120 mj/cm2 Exposure Range: 110 to 145mj/cm2

MOUNT

White Light Handling Visible Image for Plate ID





DAMPEN

Engage Dampening Rollers for Several Revolutions





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